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S. K. Vasheghani Farahani, C. F. McConville, T. D. Veal, A. Schleife

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## Impact of degenerate *n*-doping on the optical absorption edge in transparent conducting cadmium oxide

S. K. Vasheghani Farahani and C. F. McConville

Department of Physics, University of Warwick, Coventry CV4 7AL, United Kingdom

T. D. Veal

Stephenson Institute for Renewable Energy and Department of Physics, School of Physical Sciences, University of Liverpool, Liverpool, L69 4ZF, United Kingdom

André Schleife

Condensed Matter and Materials Division, Lawrence Livermore National Laboratory, Livermore, California 94550, USA

#### **ABSTRACT**

In order to facilitate the development of next-generation display devices or modern solar cells, material performance is critically important. A combination of high transparency in the optical spectral range and high electrical conductivity under ambient conditions is attractive, if not crucial, for many applications. While the doping-induced presence of free electrons in the conduction bands of CdO can increase the conductivity up to values desired for technological applications, it is, however, expected to impact the optical properties at the same time. More specifically, variations of the band gap, effective electron mass, and optical-absorption onset have been reported. In this work recent results from modern theoretical-spectroscopy techniques are compared to experimental values for the optical band gap in order to discuss the different effects that are relevant for an accurate understanding of the absorption edge in the presence of free electrons with different concentrations.

**Keywords:** cadmium oxide, parameter-free calculations, electronic structure, effective mass, Burstein-Moss shift, bandgap renormalization, optical absorption

### 1. INTRODUCTION

Transparent conducting oxides (TCOs) are currently attracting enormous interest because they combine many different promising materials properties. Most importantly, they feature large fundamental band gaps, leading to transparency across parts of or the entire visible spectral range. While this causes ideal bulk TCOs to be insulating, it turns out that free carriers play an important role and many TCOs are either intrinsically n-type or can be heavily doped.

Transparent conductive cadmium oxide (CdO) thin films, for instance, have been known at least since 1907 and, in that sense, CdO can be seen as a pioneering TCO.<sup>1</sup> Pure bulk CdO has a band gap of about 2.1-2.3 eV,<sup>2</sup> but even undoped samples of this material can show high unintentional electron concentrations as large as  $10^{20}$  cm<sup>-3</sup>.<sup>3</sup> In addition, also intentional doping has been achieved, leading to free-electron concentrations up to  $2 \times 10^{21}$  cm<sup>-3</sup>.<sup>4,5</sup> Material properties like these enable applications of TCOs e.g. in the context of transparent electronics,<sup>6</sup> photovoltaics,<sup>7</sup> and, more recently, they are also discussed as potential candidates for low-loss plasmonics.<sup>8</sup>

While the presence of free electrons is essential for many of these technological applications of TCOs, the impact of the free carriers on the electronic (e.g. fundamental band gaps, effective electron masses) and the optical-absorption properties is the still subject of recent debate.<sup>2,9,10,11</sup> Specifically, as elucidated for zinc oxide in Refs. 11,12,13, the free electrons in

Further author information:

S. K. Vasheghani Farahani: E-mail: sepehr.vasheghani-farahani@warwick.ac.uk

C. F. McConville: E-mail: C.F.McConville@warwick.ac.uk, Telephone: +44 24 7652 4236

T. D. Veal: E-mail: t.veal@liverpool.ac.uk, Telephone: +44 151 794 3872

A. Schleife: E-mail: a.schleife@llnl.gov, Telephone: +1 925 422 4216

the lowest conduction band cause a strong contribution to the dielectric screening of the electron-electron interaction (EEI). While (for typical doping concentrations) this can be described by an additional Thomas-Fermi like contribution, 11, 12, 13 it does lead to a reduction of the quasiparticle band gap<sup>14,15</sup> and also of the exciton binding energy.<sup>11,12,13</sup> In addition, ionized-impurity scattering (IIS) reduces the quasiparticle band gap;<sup>15</sup> the sum of the EEI and the IIS contributions is called band-gap renormalization (BGR) in the following. The free electrons also occupy the lowest conduction-band states in the doped system which is why transitions from the valence bands into those states no longer contribute to the opticalabsorption spectrum. As a consequence of this so-called Pauli blocking, an apparent increase of the optical band gap emerges and is known as Burstein-Moss shift (BMS) in the literature. 16,17 In Ref. 18 it was shown for zinc oxide that modeling BMS using a parabolic two-band model is not sufficient.

In the present work modern parameter-free electronic-structure methods based on many-body perturbation theory and optical-absorption experiments are used to explore different effects of free electrons on the electronic structure and the optical absorption of n-doped CdO. In Section 2 the theoretical and the experimental approaches are briefly outlined. Results for CdO are presented and discussed in Section 3. Section 4 summarizes and concludes this paper.

### 2. COMPUTATIONAL AND EXPERIMENTAL DETAILS

The calculations in the present work are carried out using the theoretical lattice parameters derived in an earlier work, 19 based on density functional theory using a (semilocal) generalized-gradient approximation to describe the exchangecorrelation functional. However, it is well known that Kohn-Sham eigenvalues from density functional theory (along with a local or semilocal approximation to exchange and correlation) cannot be interpreted as single-particle excitation energies. Quasiparticle effects have to be taken into account, as has been shown for CdO and various other TCOs e.g. in Refs. 20, 21, 22, 23 (and references therein). Unfortunately, the corresponding parameter-free electronic-structure approaches, for instance the HSE+ $G_0W_0$  scheme, <sup>24,25,26</sup> are computationally very demanding. This constitutes a severe limitation for calculations like the ones in the present work, where a very dense sampling of k space is necessary to resolve free-electron densities on the order of  $10^{18}$  cm<sup>-3</sup>.

In order to circumvent this bottleneck, electronic structures are computed for the atomic geometries of ideal rocksalt-CdO using the GGA+ $U+\Delta$  approach, as described in Refs. 12, 13, 27, 28. It has been shown 12, 13, 28 that this scheme is capable of closely reproducing the parameter-free results of the HSE+ $G_0W_0$  approach, however, at a strongly reduced computational cost. While the U parameter is adopted from Ref. 28, it is noted that in the present work  $\Delta = 1.41 \text{ eV}$ is used to compensate for small deviations between the experimental and the theoretical band gaps that were discussed before.  $^{12,13,28}$  This also accounts (in an approximate way) for differences of the band gap at T=0 K (temperature the theoretical calculations correspond to) and T = 300 K (temperature at which the measurements have been carried out), which is justified by experiments<sup>2</sup> indicating that the variation of the optical gaps as a function of the free-carrier density are essentially the same for different temperatures.

In addition, a full parameter-free treatment of the BGR is currently numerically unfeasible and in the present work this many-body effect is described by means of the model given by Berggren and Sernelius, 15,29 which leads to the following expression for the BGR:

$$\Delta E_{\rm BGR}(n) = \left\{ \Delta E_{\rm EEI}(n) \right\} + \Delta E_{\rm IIS}(n) = \left\{ -\frac{e^2 k_{\rm F}}{2\pi^2 \varepsilon \varepsilon_0} - \frac{e^2 q_{\rm TF}}{8\pi \varepsilon \varepsilon_0} \left[ 1 - \frac{4}{\pi} \arctan\left(\frac{k_{\rm F}}{q_{\rm TF}}\right) \right] \right\} - \frac{n \, m(n) \, e^4}{4\pi \varepsilon_0^2 \varepsilon^2 \hbar^2 q_{\rm TF}^3}. \tag{1}$$

The dependence of the effective electron mass on the free-electron concentration m(n) is taken from the parabolic fit described below (black curve in Fig. 2) and the parameter-free results for the electronic band structure are used to compute both the Fermi wave vector  $k_{\rm F}$  and the Thomas-Fermi wave vector  $q_{\rm TF}$  according to:

$$k_{\rm F} = \sqrt[3]{3\pi^2 n},\tag{2}$$

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 (2)  
 $q_{\rm TF} = \sqrt{\frac{e^2}{\varepsilon_0 \varepsilon_{\rm eff}} \cdot \frac{\partial n}{\partial \varepsilon_{\rm F}}}.$  (3)

Single crystalline CdO(001) films were grown on r-sapphire by metal-organic vapor-phase epitaxy.<sup>30</sup> Samples were annealed at 400° or 600° C for between 30 and 60 minutes to obtain samples with a range of carrier concentrations.

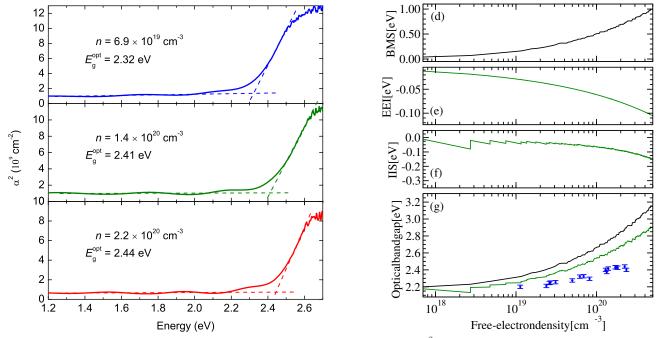


Figure 1. (Color online) Left panel: Square of optical absorption coefficient (in cm $^{-2}$ ) as a function of photon energy in the visible/ultraviolet region for free-electron concentrations of  $6.9 \times 10^{19}$  cm $^{-3}$  (a),  $1.4 \times 10^{20}$  cm $^{-3}$  (b), and  $2.2 \times 10^{20}$  cm $^{-3}$  (c). The absorption edge is determined through the extrapolation of the sharp onset and baseline of the spectra. Right panel: Dependence of Burstein-Moss shift (in eV) (d), and band-gap reduction [caused by an impact of the free electrons on the electron-electron interaction (e) as well as the ionized-impurity scattering (f)] (in eV) on the free-electron density. In (g) the resulting optical band gap is shown and blue circles with error bars represent experimental results for as-grown and post-growth annealed CdO films. Black curves in (d) and (g) neglect BGR, green curves take BGR [as computed using Eq. (1) along with an effective dielectric constant of 18] into account.

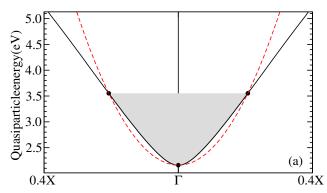
Hall effect measurements were performed in the Van der Pauw configuration. Mid-infrared and visible reflectance and transmittance measurements at an incident angle of 11° relative to the surface normal were performed using a Bruker Vertex 70v Fourier-transform infrared (FTIR) spectrometer.

#### 3. OPTICAL ABSORPTION ONSET AND EFFECTIVE ELECTRON MASSES

In Fig. 1(a)–(c) the square of the optical absorption coefficient is shown for three different samples with different free-electron concentrations. For each case, also the optical band gap is indicated. From this figure it is already clear that the optical band gap increases for larger free-carrier concentrations. In other words, this indicates that for these free-electron concentrations in CdO, the BMS is larger than the corresponding BGR. Indeed, previous results in Ref. 2 indicate that the increase of the optical gap due to BMS is equal to the decrease resulting from BGR for a free-electron concentration of  $\sim 10^{19}$  cm<sup>-3</sup>.

In order to study this trend in more detail, Fig. 1(d)-(g) shows the separate contributions that influence the optical band gap in a system with high free-electron concentrations. A fit to this data shows that the BMS is approximately proportional to  $n^{1/2}$  across the range of free-electron densities shown in Fig. 1(d). A static dielectric constant of 18 is used<sup>31</sup> in this work to evaluate Eq. 1 and this effectively takes several aspects of the screening into account in an approximative way: In addition to ionic contributions, the purely electronic screening in the doped system is expected to be reduced with respect to the ideal bulk material because of the band-gap increase caused by the BMS. Test calculations showed a reduction of the high-frequency dielectric constant of about 0.4 when going from ideal bulk to a free-electron concentration of about  $0.7 \times 10^{20}$  cm<sup>-3</sup>. We note that a full parameter-free calculation of the dielectric screening as well as the BGR would be desirable.

Adding BMS and BGR to the band gap of 2.16 eV leads to the behavior shown in Fig. 1(g). As expected, this plot shows that the theoretical curve that entirely neglects BGR does not agree well with the experimental results; taking BGR



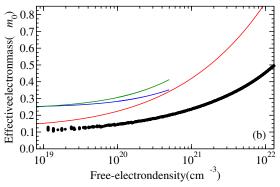


Figure 2. (Color online) Black curve in (a) shows the theoretical result for the lowest conduction band in the vicinity of the  $\Gamma$  point of the Brillouin zone. Grey shaded area indicates a conduction-band filling of about  $8 \times 10^{20}$  cm<sup>-3</sup>, corresponding to a Fermi level about 1.4 eV above the conduction-band minimum. Red dashed represents a parabolic fit to the band structure. In (b) the dependence of the effective electron mass on the free-electron concentration is shown: Black dots are computed from the theoretical band structure using Eq. (4), red solid line takes the non-parabolicity into account (see Ref. 32).

into account significantly improves the agreement.

In addition, the theoretical results also yield a highly accurate description of the position of the Fermi level in the conduction band [cf. Fig. 2(a)] as a function of the free-electron concentration. In the following we use these results along with the dispersion relation of a parabolic band and Eq. (2) to compute the dependence of the electron mass on the free-electron concentration according to

$$\frac{m(n)}{m_0} = \frac{n^{2/3}}{E_F} \cdot \frac{\hbar^2 \left(3\pi^2\right)^{2/3}}{2m_0}.$$
 (4)

These results are shown in Fig. 2(b) over a large range of free-carrier concentration and we note that this procedure effectively averages over all directions in k space. In Fig. 2(b) we compare to the effective mass at the Fermi energy, taking the non-parabolicity into account [cf. Eq. (6) in Ref. 32]. We note that the results in this work are obtained for "rigid" electronic structure, i.e., any *deformation* of the lowest conduction band due to the free electrons is neglected.

The remarkable increase of the effective electron mass observed in this figure clearly arises due to the non-parabolicity of the lowest conduction band of CdO. This is shown in Fig. 2(a) along with a parabolic fit directly to the theoretical band structure. From this plot it is immediately clear that the effective mass obtained from either of these approaches will be smaller the closer the the fitting is restricted to the  $\Gamma$  point. In addition, Fig. 2(b) also shows that a parabolic approximation is fairly well justified for a **k**-space region around the  $\Gamma$  point that corresponds to free-carrier densities of about  $10^{20}$  cm<sup>-3</sup>. We confirmed that the effective mass extracted from the parabolic fit approaches the mass parameter of a non-parabolic model<sup>32</sup> to fit the band structure when the fit is restricted to the close vicinity of the  $\Gamma$  point. From these results we conclude that the effective electron mass in CdO should be about  $0.12m_0$  in the immediate vicinity of the  $\Gamma$  point.

Comparing this number to values in the literature shows reasonable agreement with numbers of about  $0.13m_0$ ,  $^{10}$   $0.14m_0$ ,  $^{33,34}$  and  $0.1m_0$ .  $^{35}$  Other references report larger numbers of about  $0.21m_0$ ,  $^3$   $0.24m_0$ ,  $^{31}$   $0.23m_0$ ,  $^{36}$  and also other theoretical results indicate effective electron masses larger than  $0.12m_0$ .  $^{28,37}$ 

#### 4. SUMMARY AND OUTLOOK

In this work we combined theoretical and experimental results to investigate the influence of free electrons on the optical absorption edge in n-doped CdO. We disentangled the contributions of Burstein-Moss shift and band-gap renormalization. We found good agreement with optical band gaps measured for CdO samples with different free-electron concentrations. In addition, we studied the dependence of the effective mass on the free-electron concentration.

From this work it is clear that this topic deserves further attention. For ZnO, the explicit influence of free electrons on the electron-hole interaction and bound excitonic states has been discussed, see e.g. Refs. 11,12,13, and it has been shown that the shape of the optical-absorption spectra is strongly influenced, in particular, in the vicinity of the absorption edge. Even though the influence of excitonic effects on the line shape of the absorption spectrum is smaller for CdO (due to

the larger dielectric screening), such a study would be insightful and, in particular, would allow for the direct comparison with experimental results, ruling out any potential artifacts arising from the fitting procedure used to derive the band gap from the absorption spectrum. Moreover, a fully parameter-free description of the quasiparticle energies in general and the band-gap renormalization in particular would be desirable. Other possible extensions of the present work are related, for instance, to free-carrier absorption <sup>38,39</sup> and inter-conduction-band absorption. <sup>11,12,13,40</sup>

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